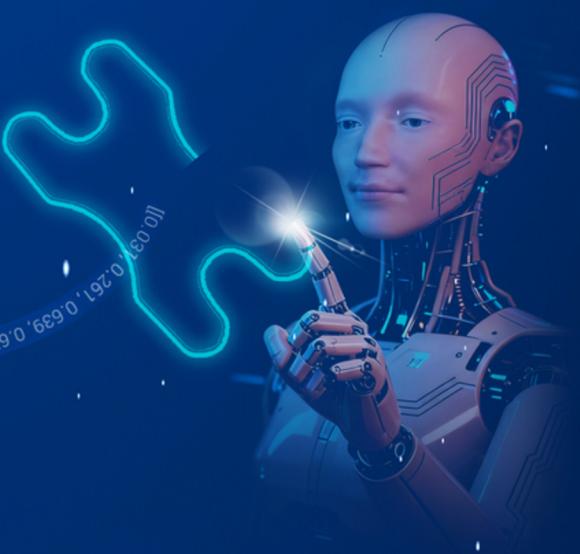
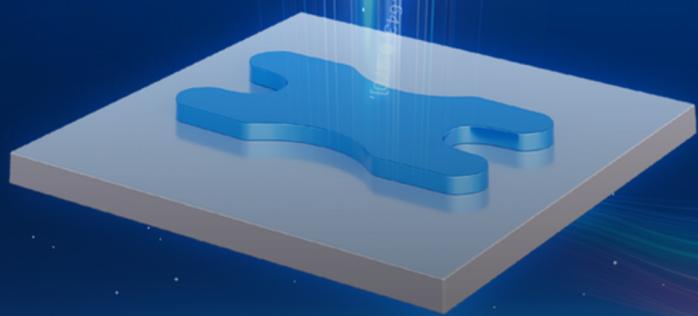


# NANOPHOTONICS

Hey Llama, design a metasurface for...

0.767 at 1050 nm, 0.694 at 1068 nm, 0.595 at 1087 nm, 0.433 at 1105 nm, 0.706 at 1123 nm

[0.03, 0.261, 0.639, 0.671, 0.821, 0.867, 0.894, 0.929, 0.967, 0.996, 0.998]



# NANOPHOTONICS

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